Claims

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- 1. Circuit arrangement (1) on a substrate (2) and comprising
- at least one semiconductor component (3) arranged on the substrate (2) and having at least one electrical contact surface (31) and
- at least one connection line (4) arranged on the substrate (2) for electrically contacting the contact surface (31) of the semiconductor component (3), characterized in that
- the electrical connection line (4) is a part (51) of at least one discrete passive electrical component (5) arranged on the substrate (2).
- 2. Circuit arrangement in accordance with claim 1, with
- the discrete passive electrical component (5) being a capacitor (53) and
- the part (51) being an electrode (531) of the capacitor (53).
- 3. Circuit arrangement in accordance with claim 1, with
- the discrete passive electrical component (5) being a coil (54) and
- the part (51) being a winding (541) of the coil (54).
- 4. Circuit arrangement in accordance with claim 1, with
- the discrete passive electrical component (5) being an electrical resistor (52) and
- the part being a wire resistor (521).
- Circuit arrangement in accordance with one of claims 1 to
 4, with the discrete passive electrical component (5)
 being a part of a sensor (7) of a physical variable.

- Circuit arrangement in accordance with one of claims 1 to
 with the semiconductor component being a power semiconductor component.
- 7. Circuit arrangement in accordance with claim 6, with the power semiconductor component being selected from the MOSFET, IGBT and/or bipolar transistor group.
- 8. Method for producing a circuit arrangement in accordance with one of claims 1 to 7, with the method steps:
- a) production of a semiconductor component on a substrate with an electrical contact surface that is facing away from the substrate, and
- b) production of the electrical connection line, with the contact surface of the semiconductor component being contacted and the part of the discrete passive electrical component being produced.
- 9. Method in accordance with claim 8, with, in order to provide the semiconductor component on the substrate the semiconductor component being arranged on the substrate in such a way that the electrical contact is facing away from the substrate, and a layer of electrically insulating material is applied to the semiconductor component and the substrate in such a way that the electrical contact is freely accessible.
- 10. Method in accordance with claim 8 or 9, with a complete layer of electrically insulating material being first applied and the contact being exposed after the application by opening a window in the layer of electrically insulating material.